

Figure 1: P Channel MOSFET Level 2 model

*Form:*

**mosp2:**(instance name)  $n_1$   $n_2$   $n_3$   $n_4$  <parameter list>

- $n_1$  is the drain node,
- $n_2$  is the gate node,
- $n_3$  is the source node,
- $n_4$  is the bulk node.

*Parameters:*

Parameter	Type	Default value	Required?
vt0: Zero bias threshold voltage (V)	DOUBLE	0	no
kp: Transconductance parameter ( $A/V^2$ )	DOUBLE	$2 \times 10^{-5}$	no
gamma: Bulk threshold parameter ( $V^{0.5}$ )	DOUBLE	0	no
phi: Surface inversion potential (V)	DOUBLE	0.6	no
lambda: Channel-length modulation ( $1/V$ )	DOUBLE	0	no
rd: Drain ohmic resistance ( $\Omega$ )	DOUBLE	0	no
rs: Source ohmic resistance ( $\Omega$ )	DOUBLE	0	no
is: Bulk junction saturation current (A)	DOUBLE	$1 \times 10^{-14}$	no
pb: Bulk junction potential (V)	DOUBLE	0.8	no
js: Bulk junction saturation current density (A)	DOUBLE	0	no
tox: Oxide thickness (m)	DOUBLE	$1 \times 10^{-7}$	no
ld: Lateral diffusion length (m)	DOUBLE	0	no
u0: Surface mobility ( $cm^2/V\cdot s$ )	DOUBLE	600	no
fc: Forward bias junction fit parameter	DOUBLE	0.5	no
nsub: Substrate doping ( $cm^{-3}$ )	DOUBLE	$1 \times 10^{15}$	no
tpg: Gate material type	DOUBLE	1	no
nss: Surface state density ( $cm^{-2}$ )	DOUBLE	0	no
delta: Width effect on threshold	DOUBLE	0	no
uexp: Crit. field exp for mob. deg.	DOUBLE	0	no
ucrit: Crit. field for mob. degradation	DOUBLE	$1 \times 10^4$	no
vmax: Maximum carrier drift velocity	DOUBLE	0	no
xj: Junction depth	DOUBLE	0	no
neff: Total channel charge coeff.	DOUBLE	1	no
nfs: Fast surface state density	DOUBLE	0	no
tnom: Nominal temperature (C)	DOUBLE	27	no
kf: Flicker noise coefficient	DOUBLE	0	no
af: Flicker noise exponent	DOUBLE	1	no
t: Device temperature (C)	DOUBLE	27	no
l: Device length (m)	DOUBLE	$2 \times 10^{-6}$	no
w: Device width (m)	DOUBLE	$50 \times 10^{-6}$	no
alpha: Impact ionization current coefficient	DOUBLE	0	no

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*Example:*

mosp2:p1 2 3 0 0 l=1.2u w=20u

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*Description:*

*f*REEDA<sup>™</sup> has the NMOS level 2 model based on the MOS level , Grove-Frohman model in SPICE. The model uses the charge conservative Yang-Chatterjee model for modeling charge and capacitance.

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*Notes:*

This is the M element in the SPICE compatible netlist. The unmodified Yang-Chatterjee charge model has a charge partition scheme in the saturation region that sets the drain charge to zero. This results in a loss of the high-frequency current roll-off at the drain node in saturation.


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*Version:*

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*Credits:*

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